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ROBERTS, ABOKHAIR&MARDULA → 17038729306P2616

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JUN 28 2004

Docket No.: 5545 (2616-012)

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of

Gene LEE et al.

OFFICIAL

Appln. No.: 10/039,333

Group Art Unit: 1765

Filed: November 9, 2001

Examiner: B. Tran

Title: Method for Etching Tungsten  
Using NF<sub>3</sub> and Cl<sub>2</sub>

TRANSMITTAL LETTER

Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

Transmitted via facsimile  
to 1 703 872 9306

Dear Sir:

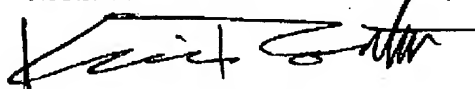
Enclosed please find the following:

1. Amendment Under 37 C.F.R. § 1.111; and
2. Petition for Extension of Time.

The Director of the U.S. Patent & Trademark Office is hereby authorized to charge the statutory fee of \$110.00 to Deposit Account No. 18-1579. The Director is also authorized to charge any fee deficiency, or credit any overpayment, to Deposit Account No. 18-1579.

Respectfully submitted,

ROBERTS ABOKHAIR & MARDULA, LLC



Kevin L. PONTIUS  
Reg. No. 37512  
(505) 922-1400

Date: June 28, 2003

Atty. Dkt. No.: 5545 (2616-012)